

REOSC

DEFLECTOMETRY APPLIED TO FREEFORM AND LARGE OPTICAL SURFACE METROLOGY

ELBERETH 2020

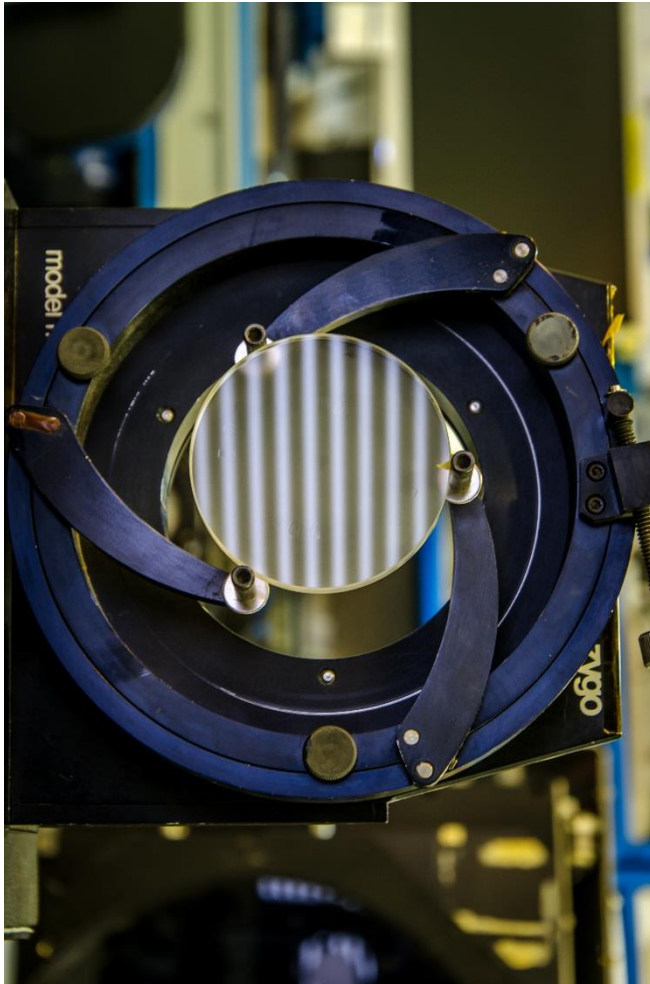
Hugo Jonquière

Renaud MERCIER YTHIER



Laurent MUGNIER
Vincent MICHAU





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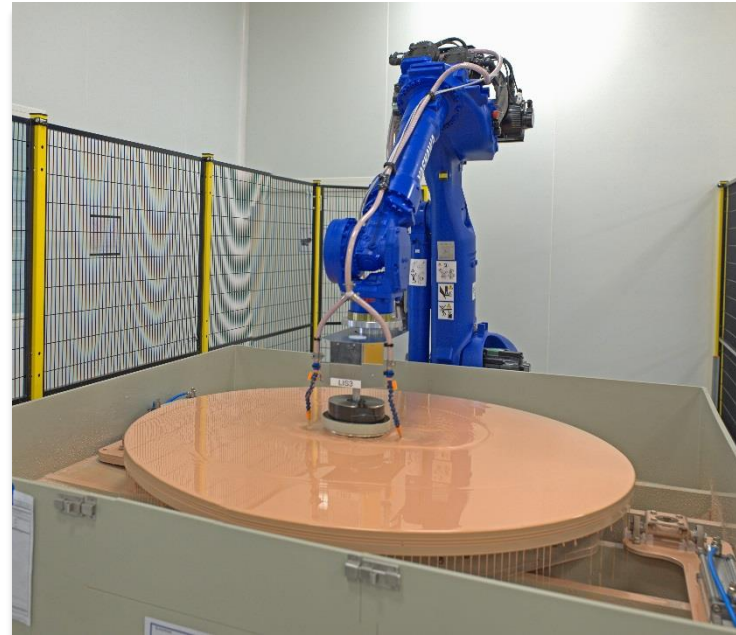
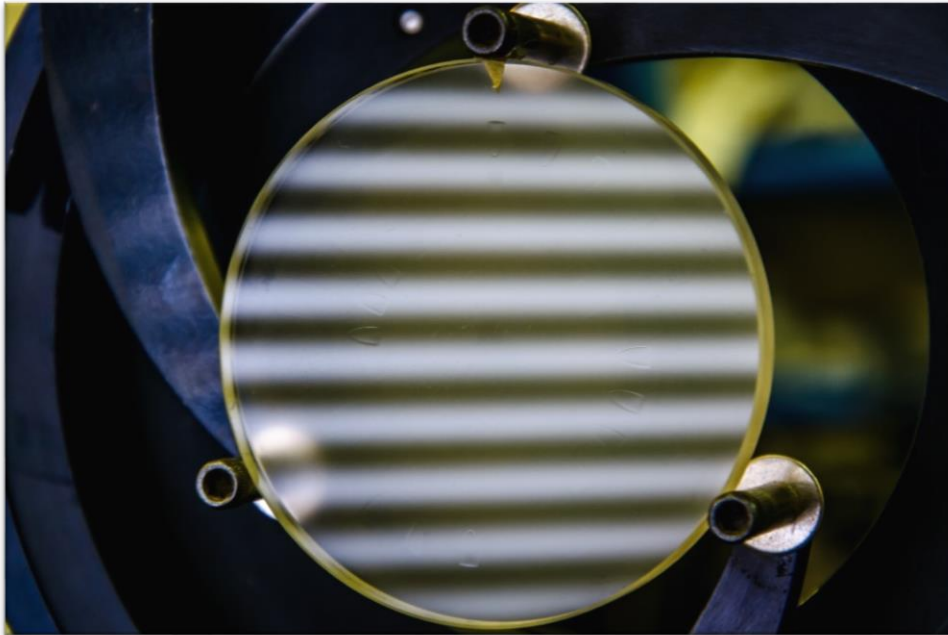
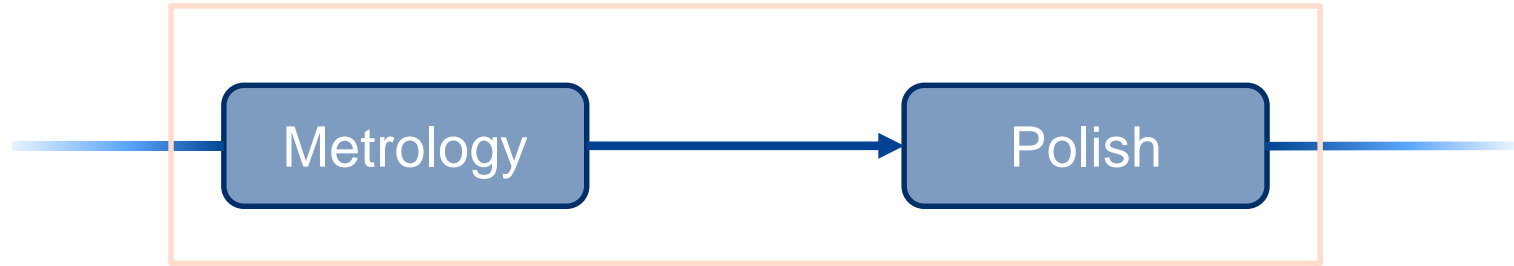
**III – RESEARCH AXIS &
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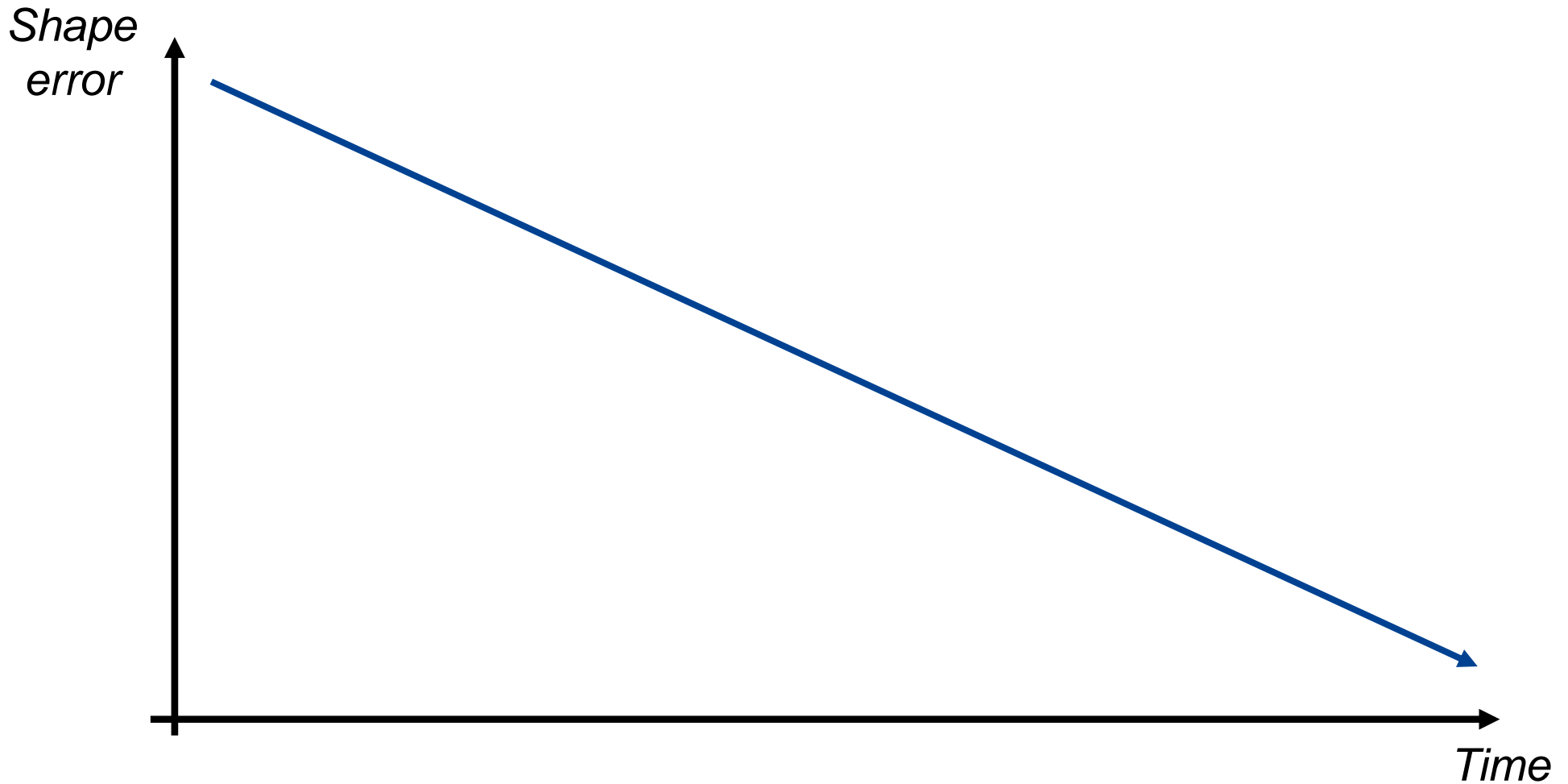
OPTICAL FABRICATION



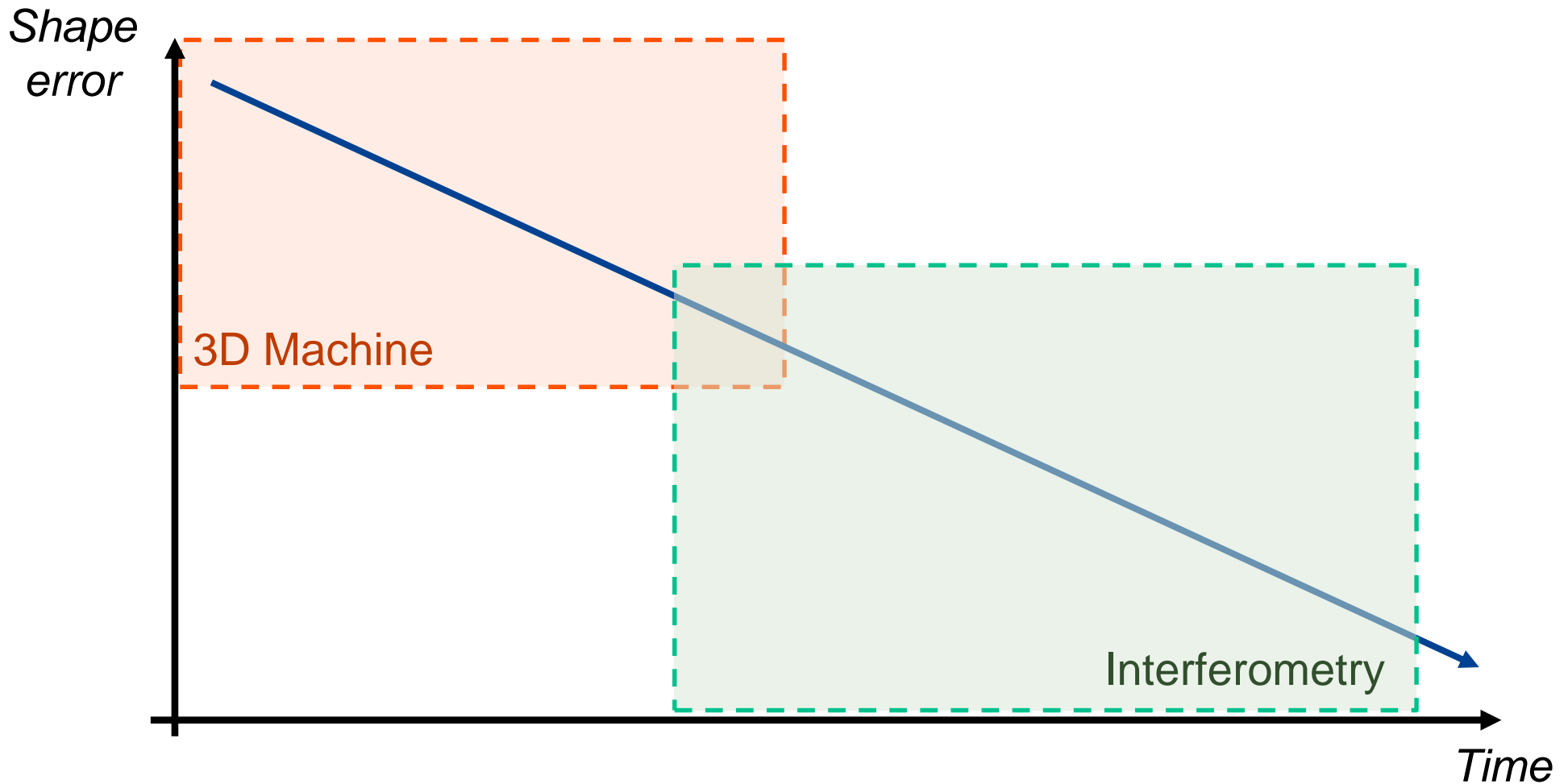
Optical fabrication : an iterative process



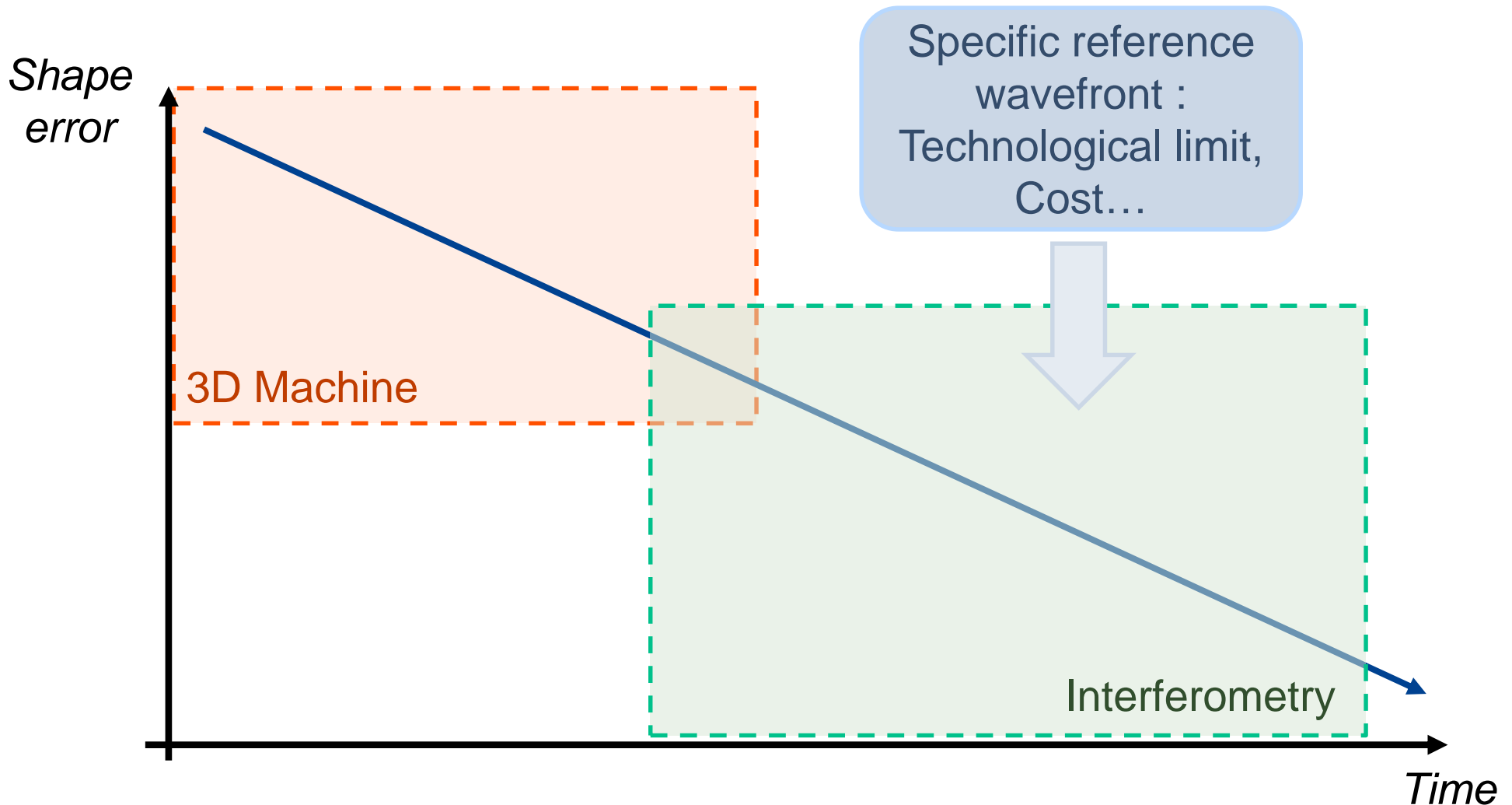
Polishing progress : large optics



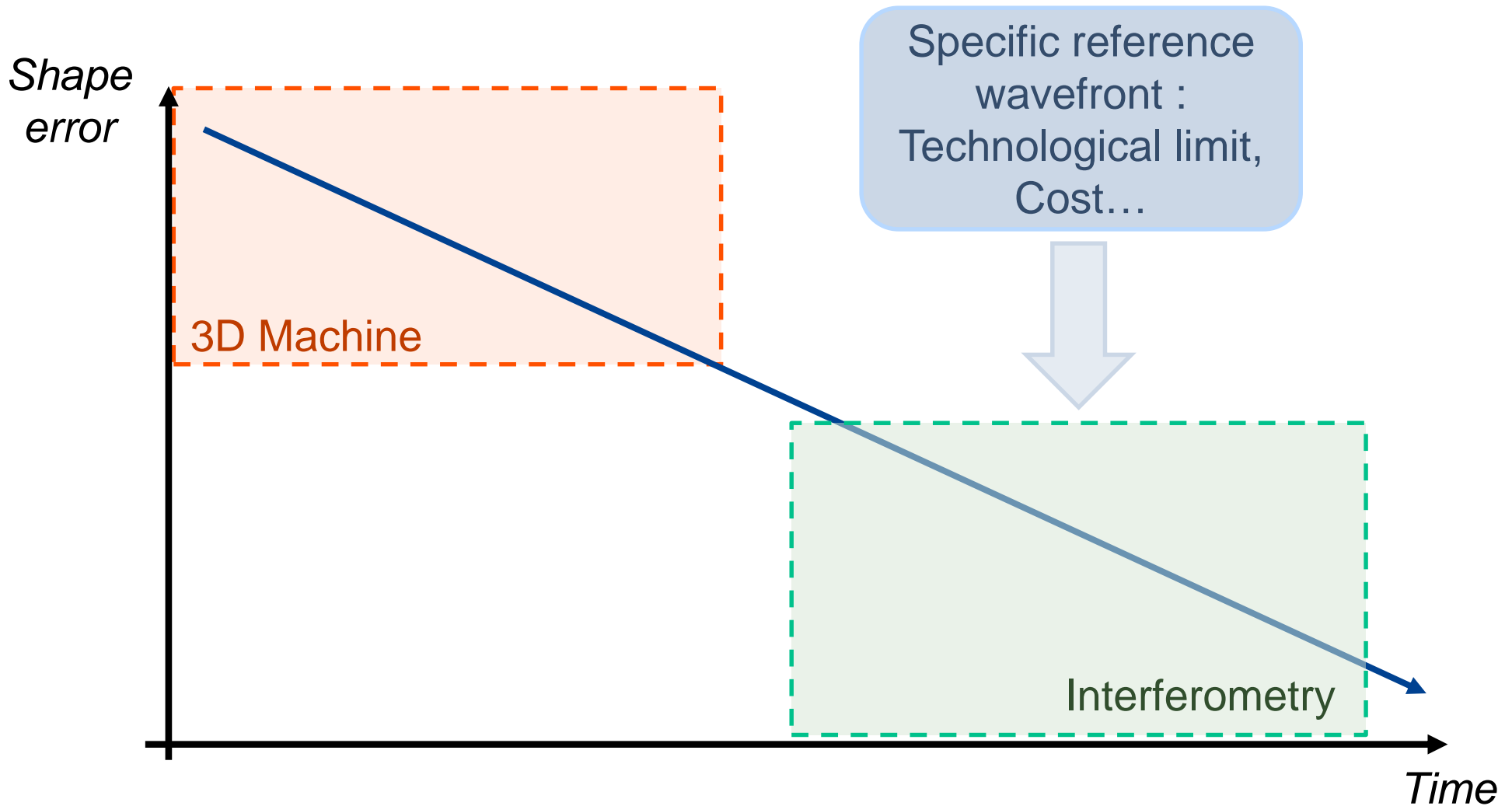
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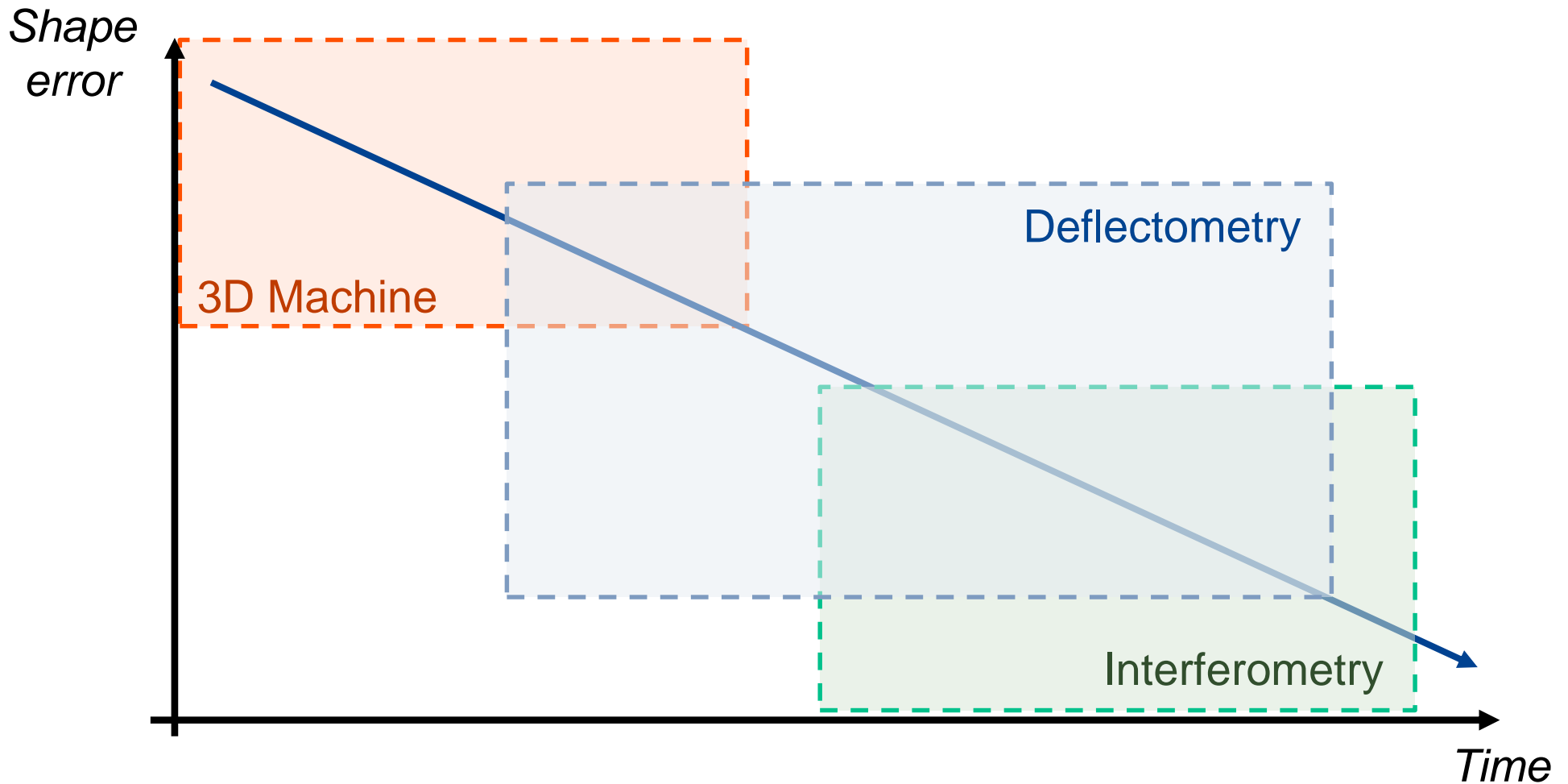
Polishing progress : large optics



Polishing progress : large optics



Polishing progress :



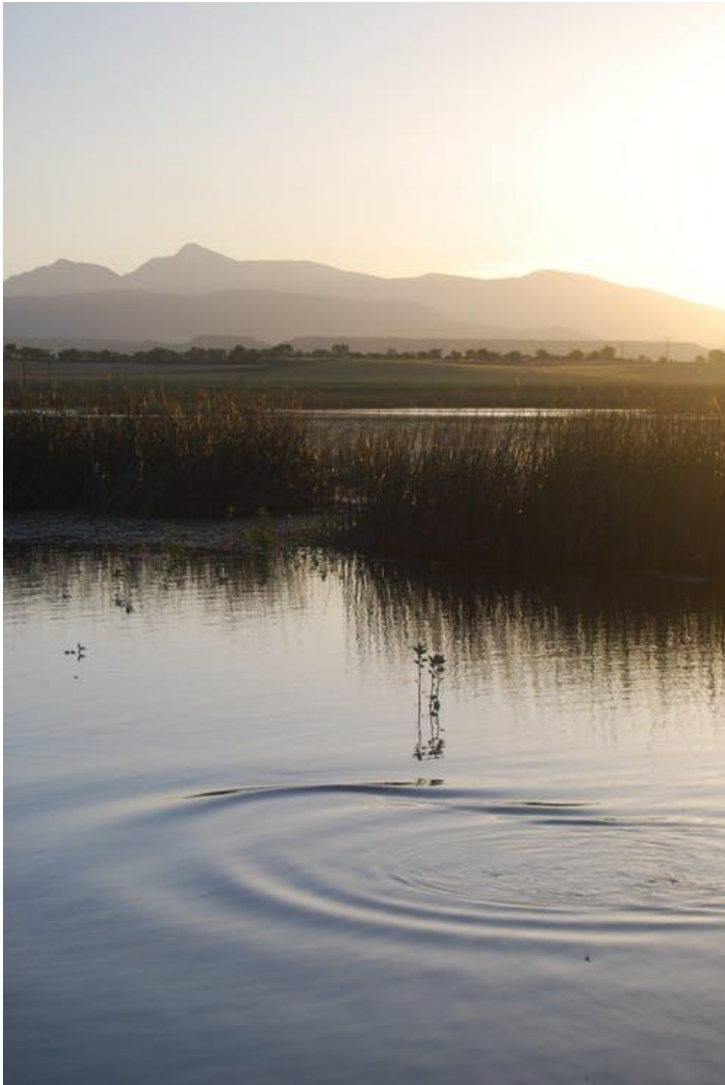
2



DEFLECTOMETRY : PRINCIPLE

Deflectometry : Principle

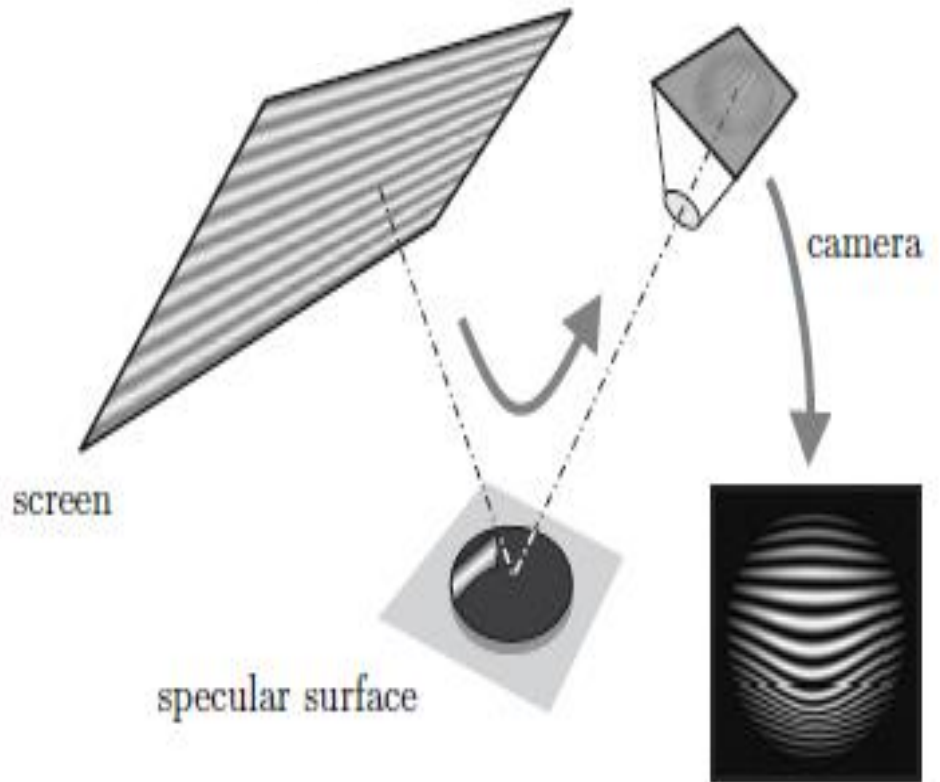
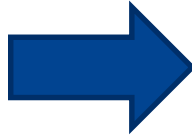
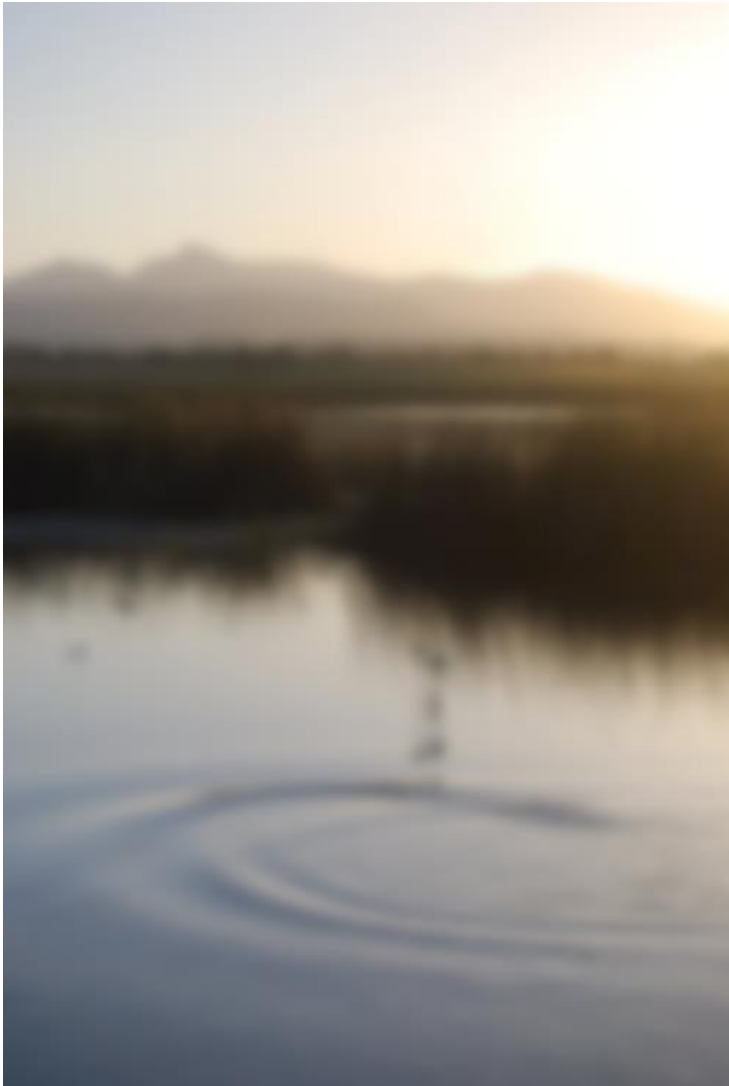
Extract a mirror's shape from a pattern's reflexion



Deflectometry : Principle

Image from *Phase Measuring Deflectometry: a new approach to measure specular free-form surfaces*, Markus C. Knauer, Jurgen Kaminski and Gerd Hausler

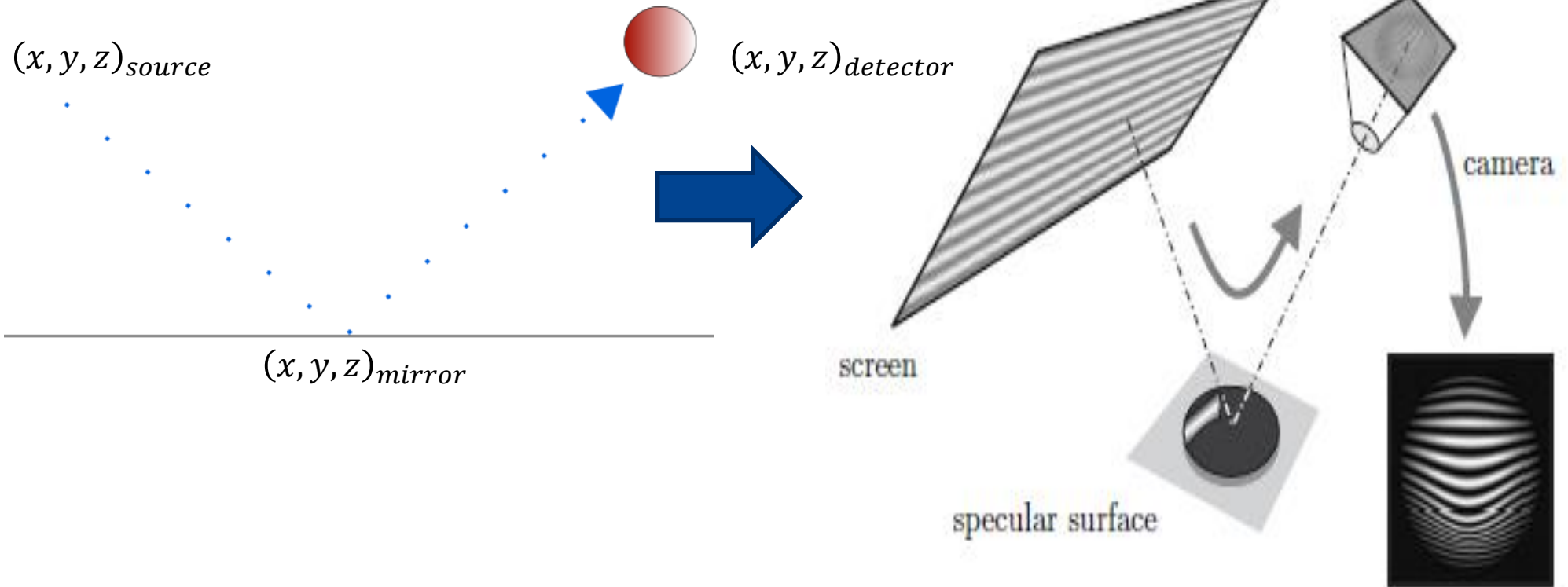
Extract a mirror's shape from a pattern's reflexion



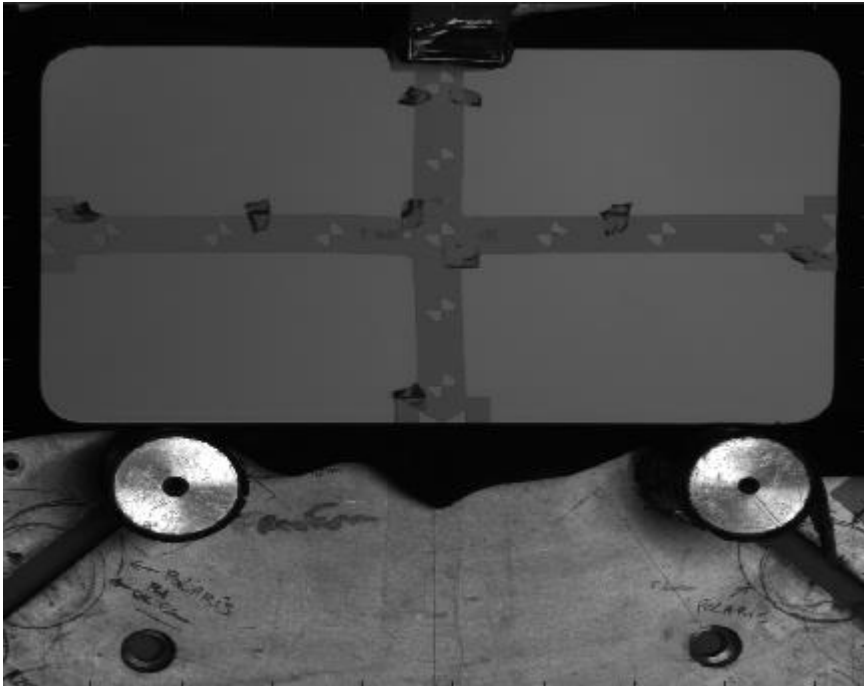
Deflectometry : Principle

Image from *Phase Measuring Deflectometry: a new approach to measure specular free-form surfaces*, Markus C. Knauer, Jurgen Kaminski and Gerd Hausler

Extract a mirror's shape from a pattern's reflexion



How to associate source, mirror and detector ?

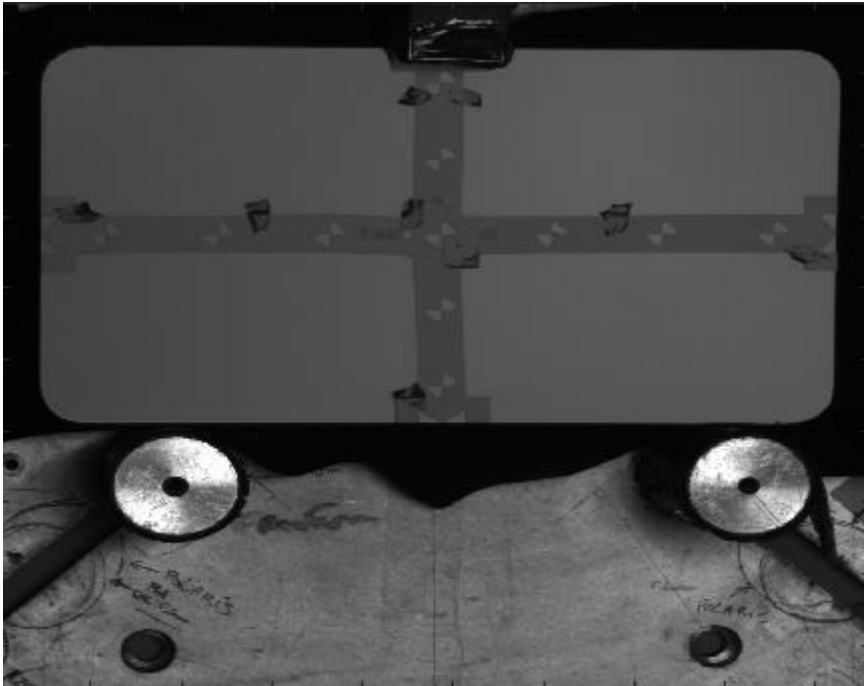


Fiducials



Phase Shift algorithm

How to associate source, mirror and detector ?



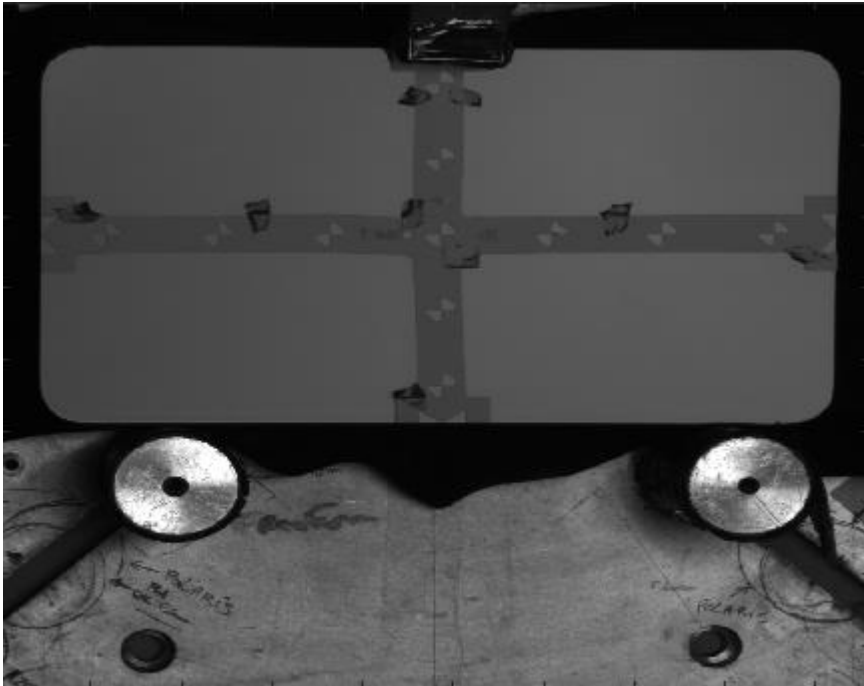
Fiducials

1 pixel \Leftrightarrow 1 mirror pixel



Phase Shift algorithm

How to associate source, mirror and detector ?



Fiducials

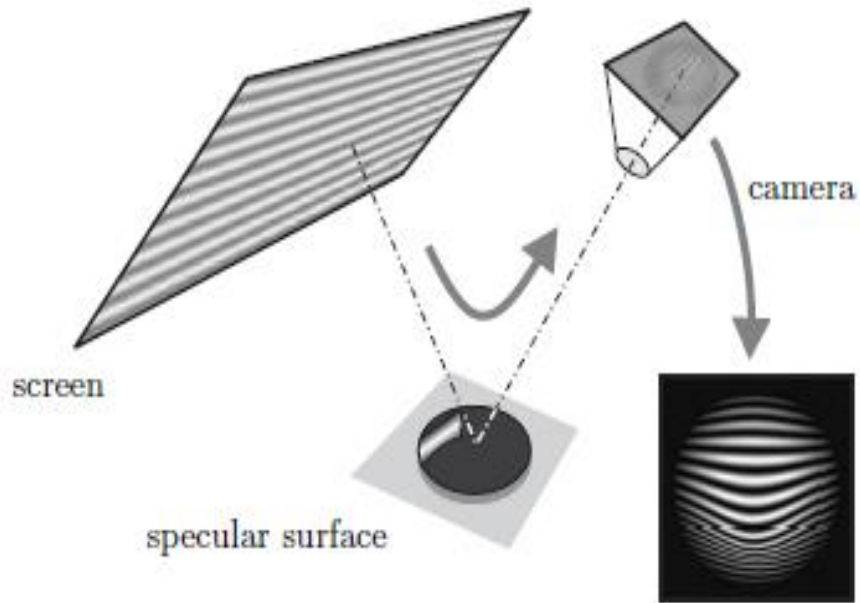
1 pixel \Leftrightarrow 1 mirror pixel



Phase Shift algorithm

1 pixel \Leftrightarrow 1 source pixel

Summary :

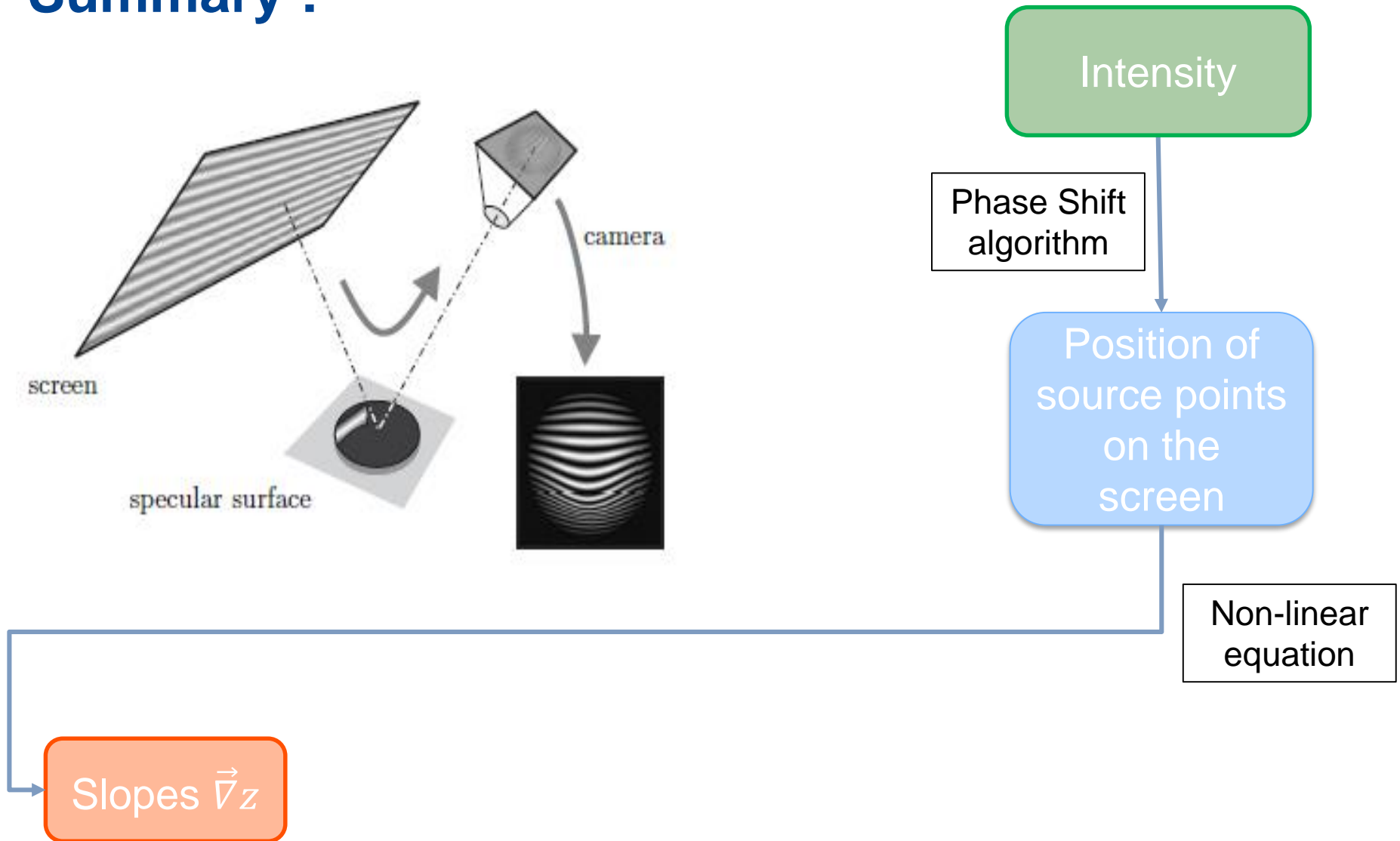
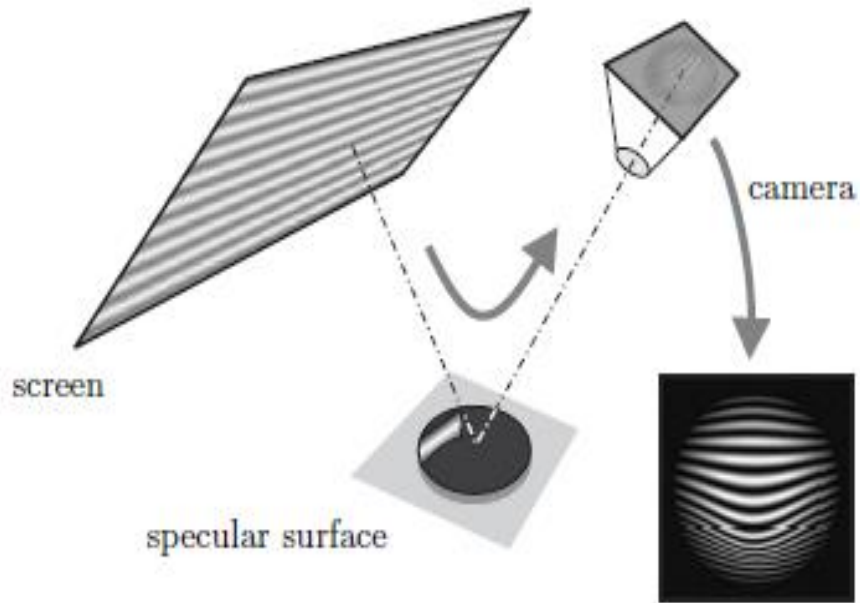


Intensity

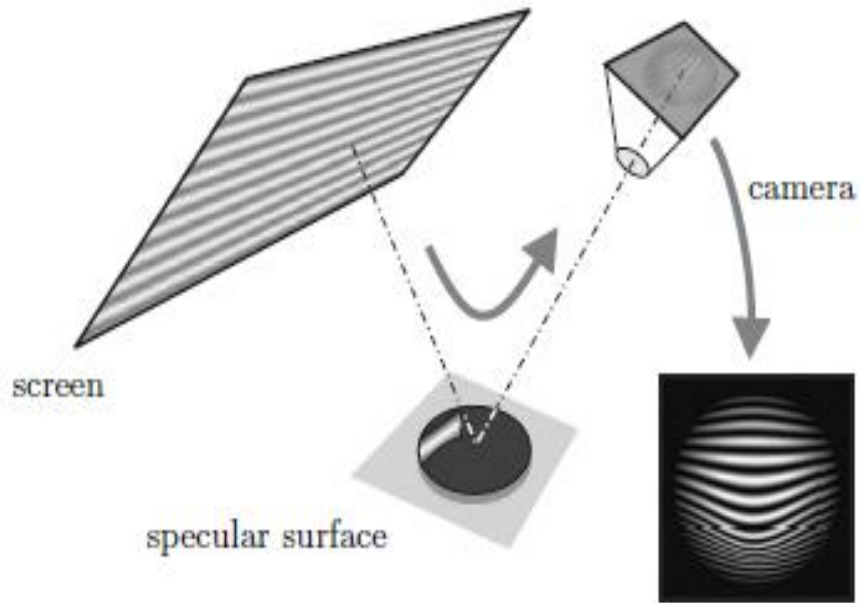
Position of source points on the screen

Slopes $\vec{\nabla}_z$

Summary :



Summary :



Intensity

Phase Shift algorithm

Position of source points on the screen

Non-linear equation

Slopes $\vec{\nabla} z$

Inversion

Shape z

$$\vec{\nabla} z \rightarrow z$$

Limitations & axis of research

Geometry errors bias

Print-through bias & error propagation through inversion

Low spatial frequencies :
Z8

Mid spatial frequencies :
Z8 à Z36

High spatial frequencies :
residual >Z36

Frequency

Limitations & axis of research

Geometry errors bias

Print-through bias & error propagation through inversion

Low spatial frequencies :
Z8

Mid spatial frequencies :
Z8 à Z36

High spatial frequencies :
residual >Z36

Frequency

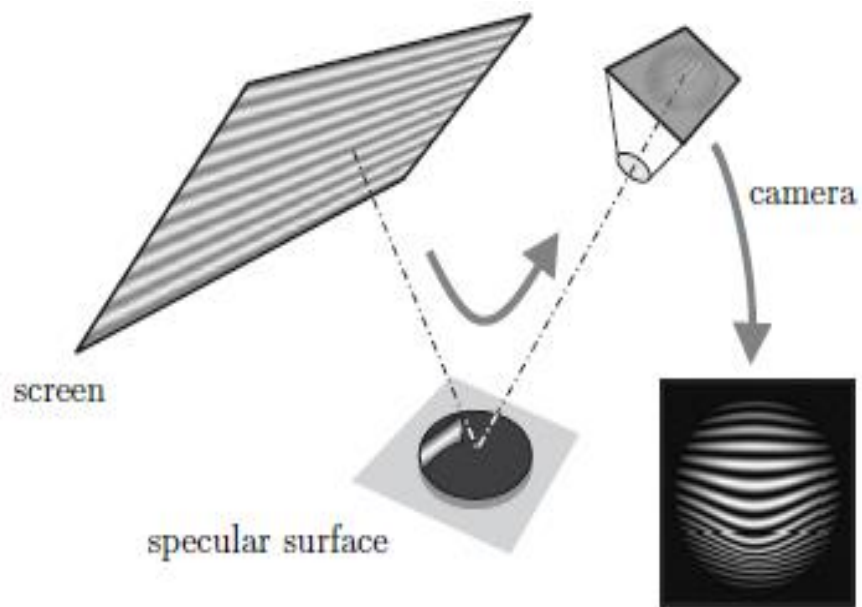
- Phase Shift algorithm robust against harmonic print-through
- Regularize the ill-conditioned inversion problem
- Auto-calibrating geometric parameters

3

RESEARCH AXIS & RESULTS



Summary :



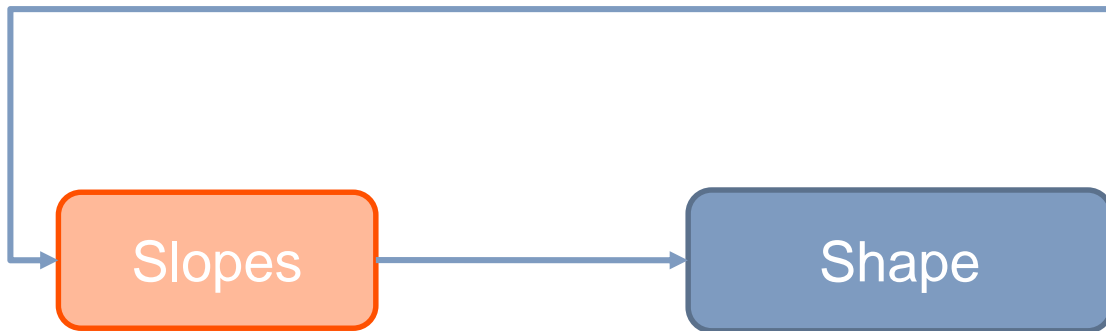
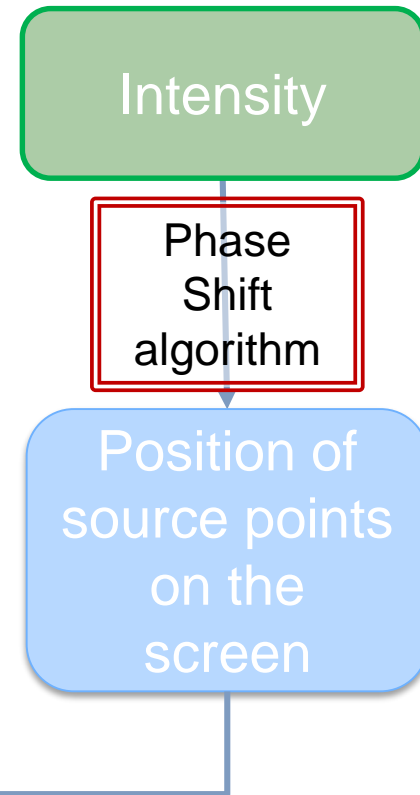
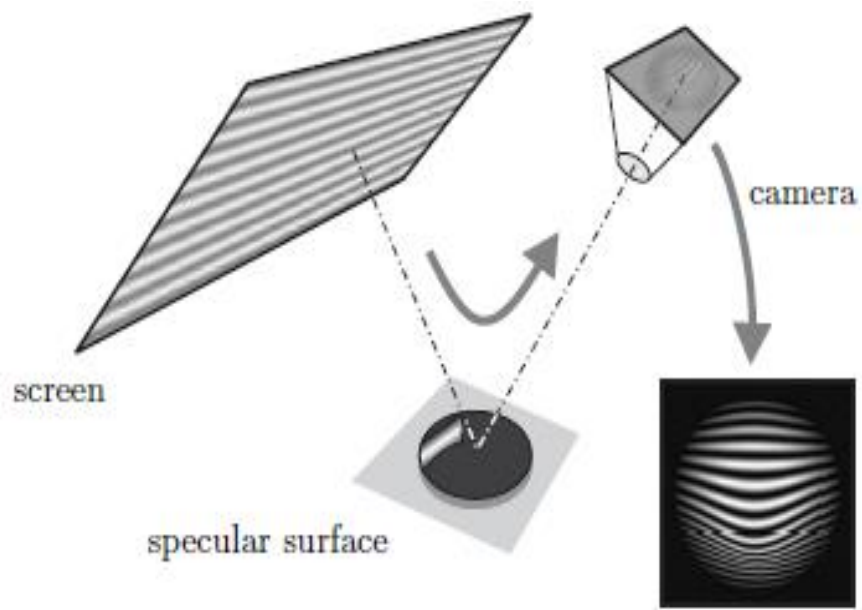
Intensity

Position of source points on the screen

Slopes

Shape

Summary :



Non-linear display impact on shape reconstruction :

Shape measured, Phase Shift algorithm robust against harmonics <4



WaRPP v 3.6.0

Calibre Plan 100mm

Date : 09/01/20

Heure : 13:31:24

MSE

L = 632,80 nm

R = 49,948 mm

Résol. : 385x385

Echelle Lin. :

-40,800 nm à

20,615 nm

106127 points

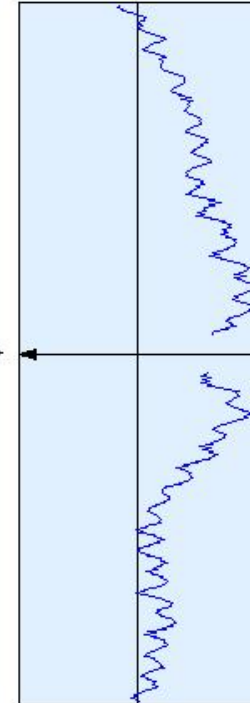
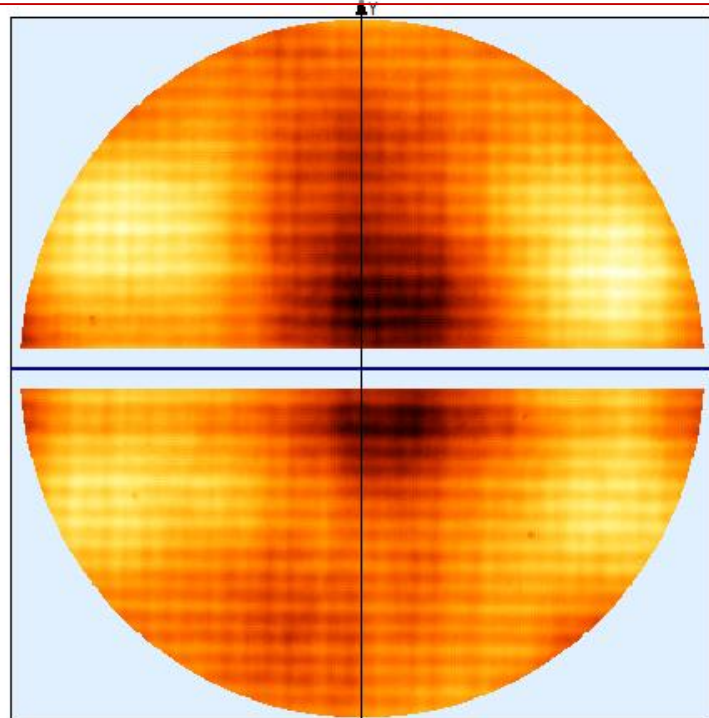
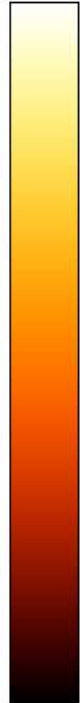
Min = -40,800 nm

Max = 20,615 nm

Moy = -8,718 nm

P-V = 61,415 nm

RMS = 10,987 nm



Intensity

Phase Shift algorithm

Position of source points on the screen

Non-linear display impact on shape reconstruction :

Shape measured, Phase Shift algorithm robust against harmonics <8



WaRPP v 3.6.0

Calibre Plan 100mm

Date : 09/01/20

Heure : 13:33:35

MSE

L = 632,80 nm

R = 49,948 nm

Résol. : 385x385

Echelle Lin. :

-39,027 nm à

16,493 nm

106127 points

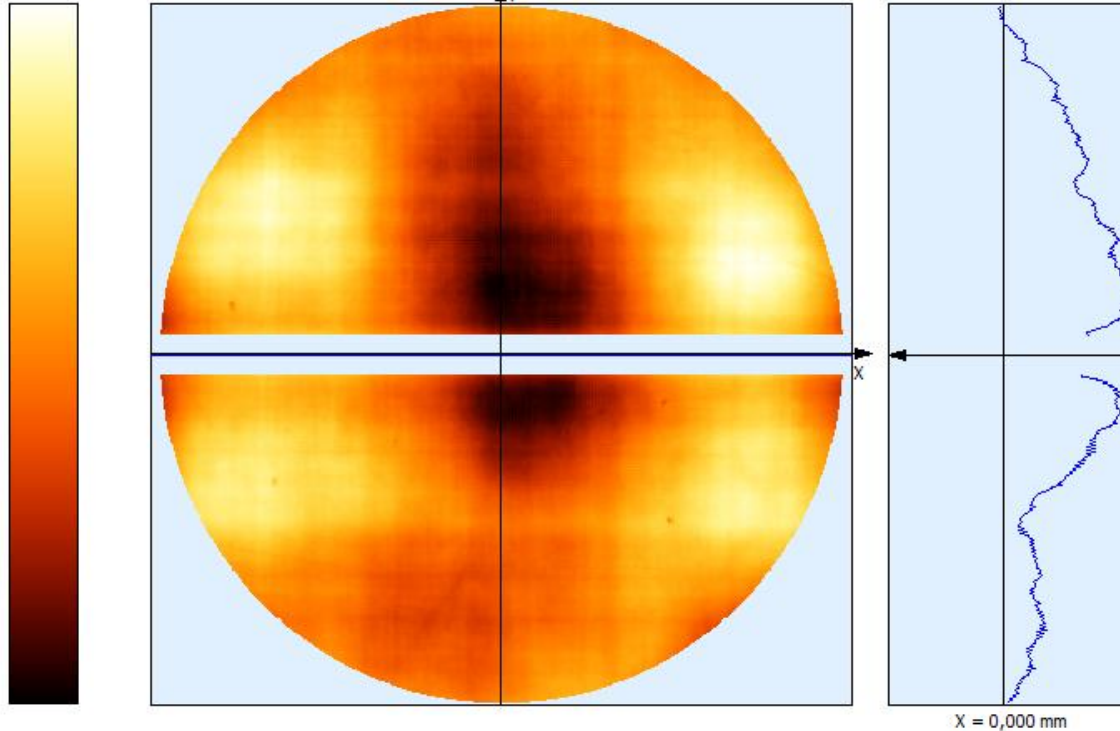
Min = -39,027 nm

Max = 16,493 nm

Moy = -9,327 nm

P-V = 55,521 nm

RMS = 11,192 nm

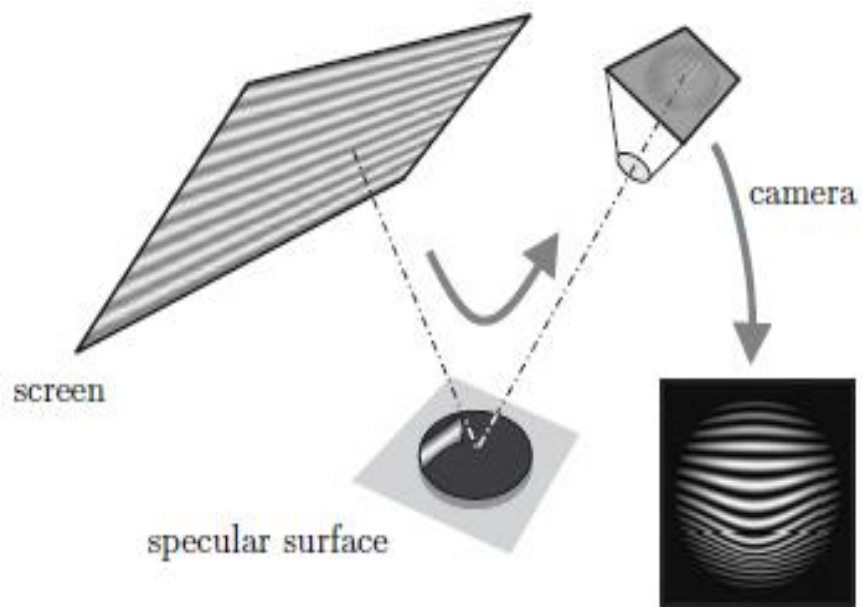


Intensity

Phase Shift
algorithm

Position of
source points
on the
screen

Summary :



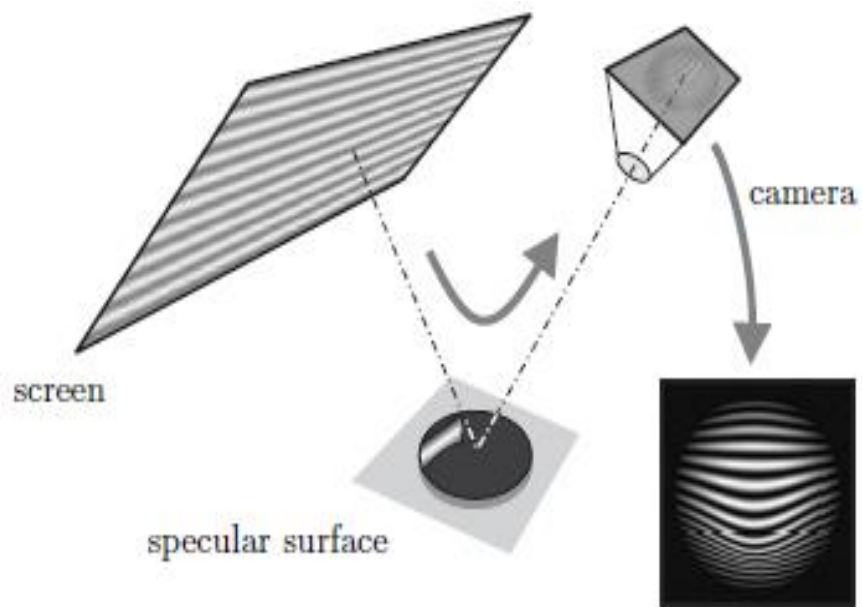
Intensity

Position of source points on the screen

Slopes

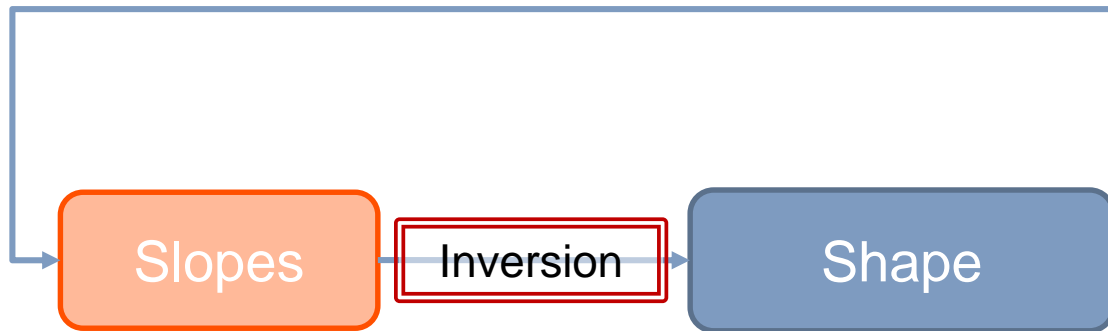
Shape

Summary :



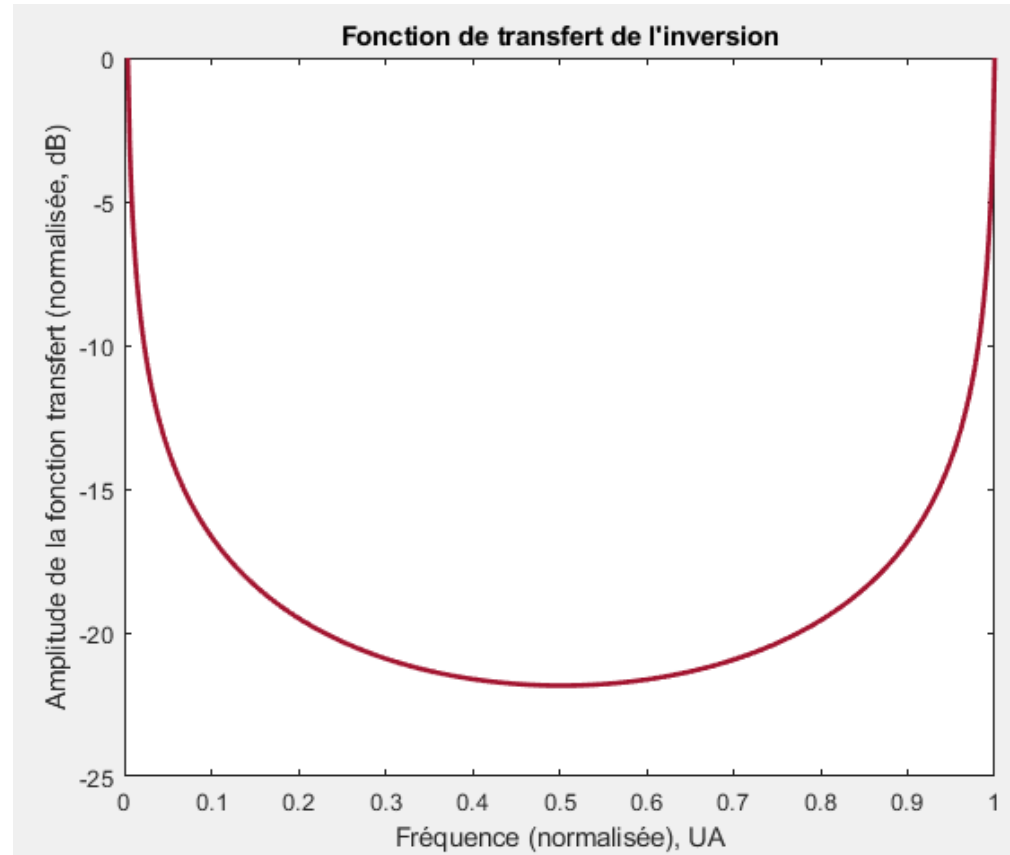
Intensity

Position of source points on the screen



High frequencies performance

Ill-conditioned inversion problem



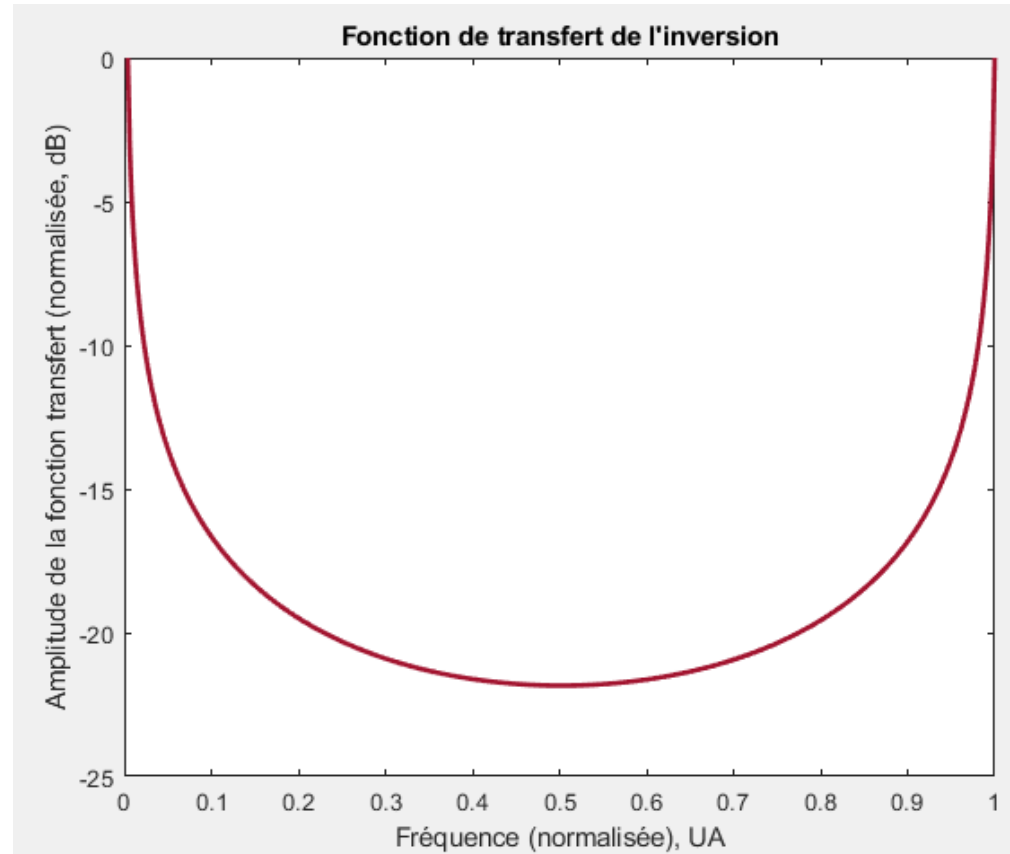
$$\tilde{z}(\vec{k}) = \frac{1}{\tilde{D}(\vec{k})} \tilde{V} z(\vec{k})$$

High frequencies performance

Ill-conditioned inversion problem



Regularization methods
(Maximum a posteriori estimation)



High frequency noise amplification

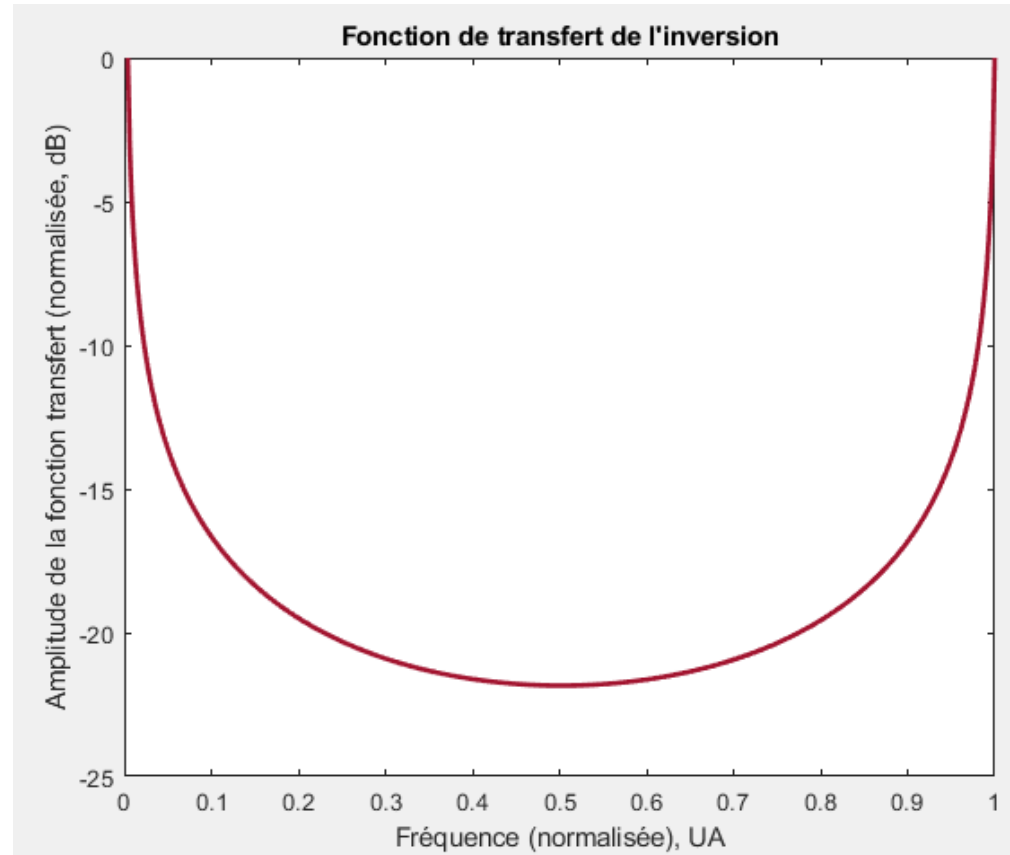
High frequencies performance

Ill-conditioned inversion problem



Regularization methods
(Maximum a posteriori estimation)

Polishing physics
→ PSD distribution hypothesis



High frequency noise amplification

Another use of regularization : inpainting



WaRPP v 3.6.0

ZU_M1_TX_QM_

Date : 09/01/20

Heure : 13:53:23

MSE

L = 632,80 nm

R = 71,743 nm

Résol. : 765x765

Echelle Lin. :

-87,101 nm à

172,767 nm

371165 points

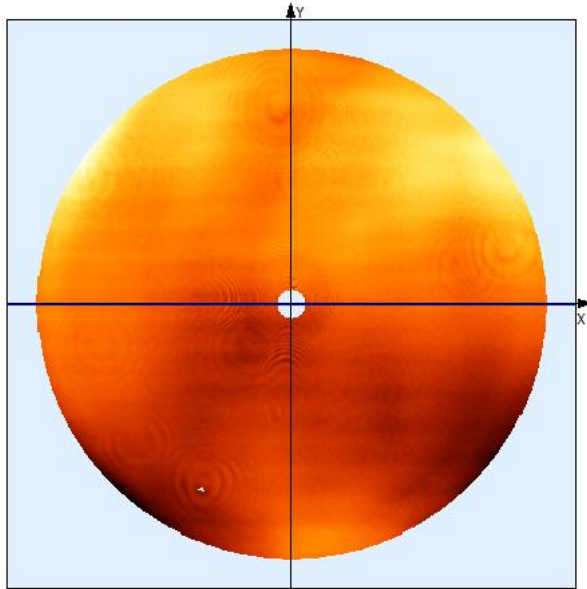
Min = -87,101 nm

Max = 172,767 nm

Moy = 26,875 nm

P-V = 259,867 nm

RMS = 44,014 nm



WaRPP v 3.6.0

ZU_M1_TX_QM_padded

Date : 09/01/20

Heure : 13:57:08

MSE

L = 632,80 nm

R = 71,743 nm

Résol. : 765x765

Echelle Lin. :

-86,663 nm à

172,636 nm

372341 points

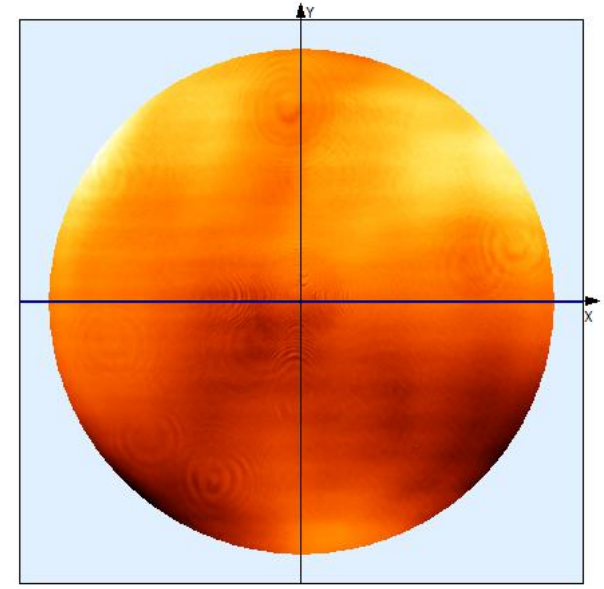
Min = -86,663 nm

Max = 172,636 nm

Moy = 26,805 nm

P-V = 259,299 nm

RMS = 43,961 nm



MERLIN : primary mirror of one lightpath

Another use of regularization : inpainting



WaRPP v 3.6.0

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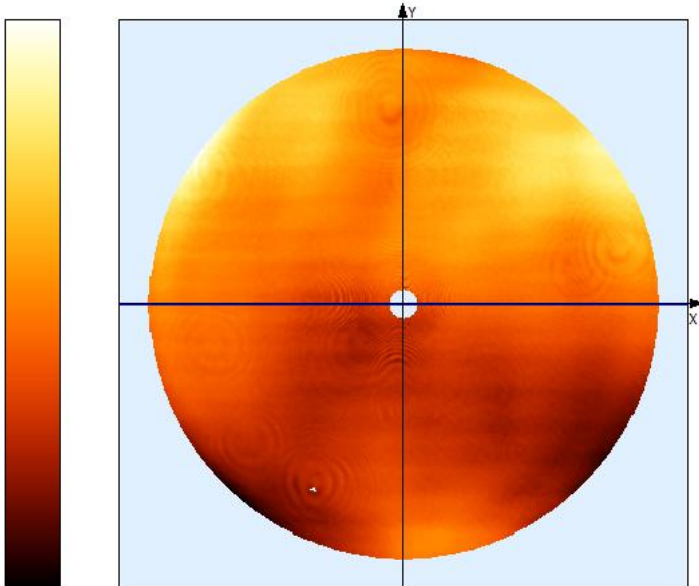
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WaRPP v 3.6.0

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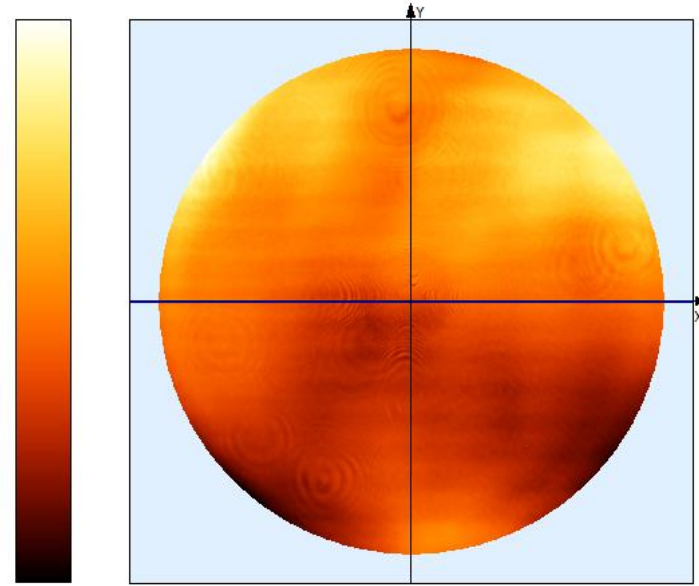
Min = -86,663 nm

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P-V = 259,299 nm

RMS = 43,961 nm



Data processing tool developed for
REOSC : in-painting & filtering

MERLIN : primary mirror of one lightpath

Capabilities :



WaRPP v 3.51

Deflectometry

Date : 18/02/20

Heure : 18:01:41

MSE

L = 632.80 nm

R = 1000.000 mm

Résol. : 1000x1000

Echelle Lin. :

27.979 nm à

1356.989 nm

389465 points

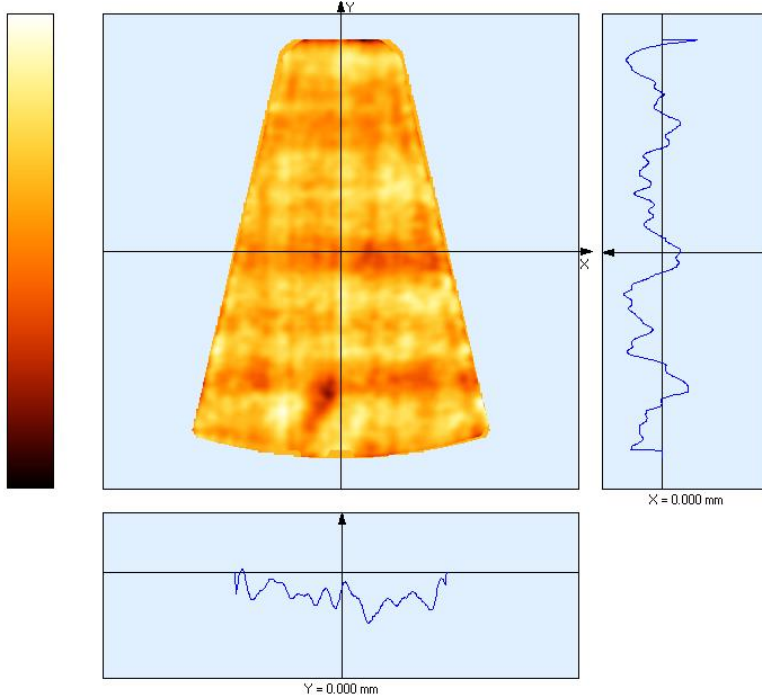
Min = 27.979 nm

Max = 1356.989 nm

Moy = 881.780 nm

P-V = 1329.010 nm

RMS = 141.849 nm



WaRPP v 3.51

Interferometry

Date : 04/02/20

Heure : 15:39:18

MSE

L = 632.80 nm

R = 1000.000 mm

Résol. : 1000x1000

Echelle Lin. :

-1268.215 nm à

515.456 nm

386708 points

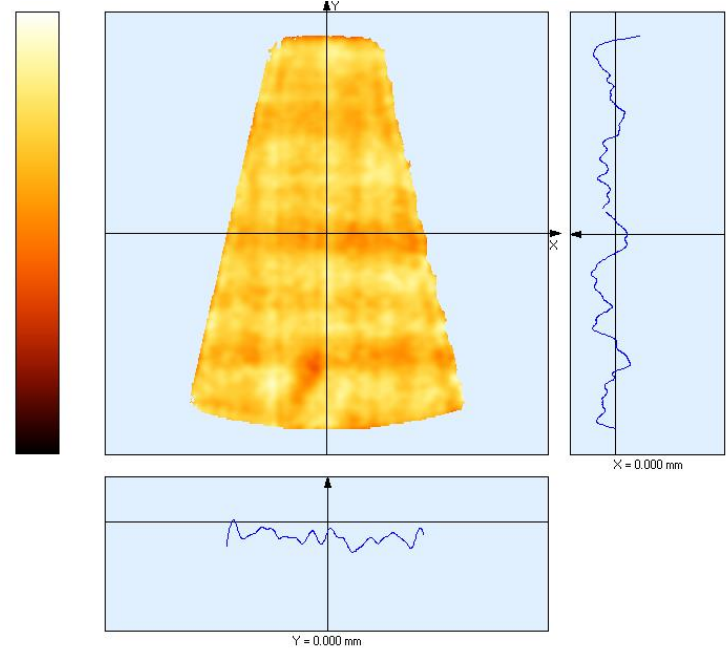
Min = -1268.215 nm

Max = 515.456 nm

Moy = 0.141 nm

P-V = 1783.671 nm

RMS = 128.159 nm



Registration & subtraction :
30 nm RMS

ELT M2 Matrix, $\phi = 2000\text{mm}$, Sub Zernike 36

Capabilities :



WaRPP v 3.51

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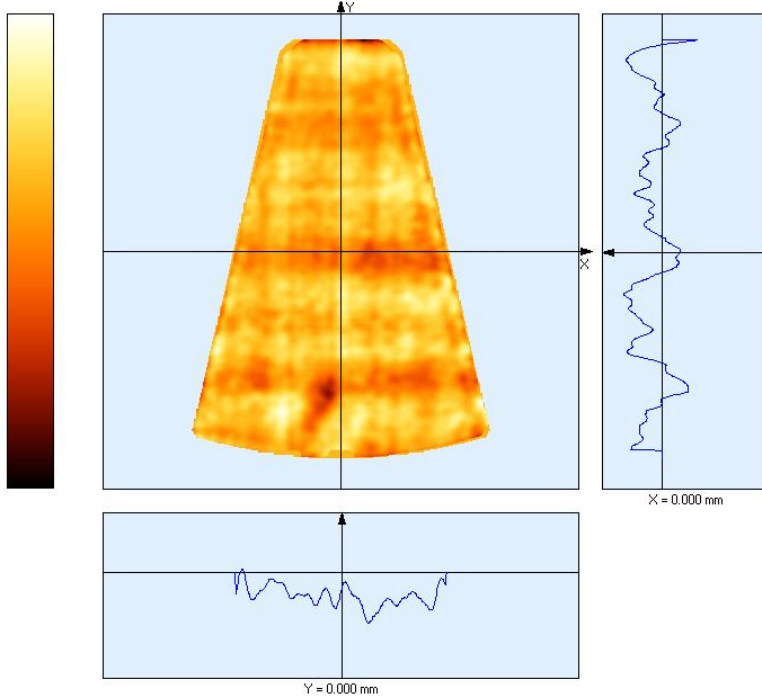
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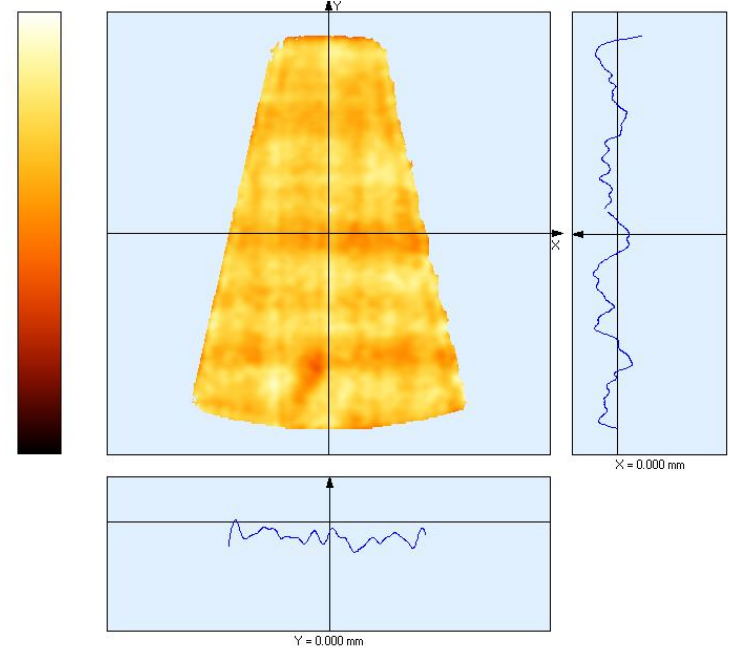
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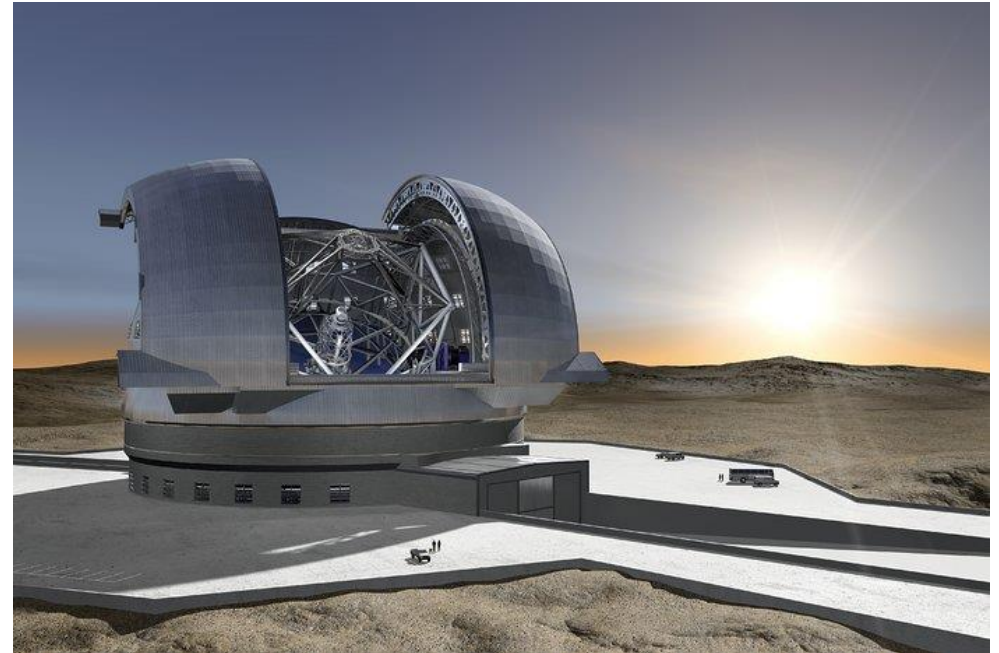
-Fast independant high frequencies measurements
-In situ capabilities

Registration & substraction :
30 nm RMS

-No specific correctors, even for freeform & aspheric mirrors
- Low cost

ELT M2 Matrix, $\phi = 2000\text{mm}$, Sub Zernike 36

Conclusion



Conclusion :

Today :

- Phase Shift algorithm robust against harmonic print-through
- Regularize the ill-conditioned inversion problem
- In-painting algorithm

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In developpement :

- Auto-calibrating geometry method

Future work :

- In situ deflectometry implementation for the fifth ELT Mirror (Plane, 2,5m diameter)
- Article to come

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Thank you for your attention !



Bibliography :

- [1] **Design of phase-detection algorithms insensitive to bias modulation**, Yves Surrel, Applied Optics, Vol. 36, Issue 4, pp. 805-807 (1997)
- [2] **Software configurable optical test system: a computerized reverse Hartmann test**, Peng Su, Robert E. Parks, Lirong Wang, Roger P. Angel, and James H. Burge, Applied Optics, Vol. 49, Issue 23, pp. 4404-4412 (2010)
- [3] **Non-null full field X-ray mirror metrology using SCOTS: a reflection deflectometry approach**, Y. W. J. H. B. a. K. K. a. M. I. Peng Su, Optics express, Vol. 20, Issue 111 (2012).